	Application No.	Applicant(s)	
Notice of Allowability	09/867,423	TANAKA ET AL.	
	Examiner	Art Unit	_
	4 . 1 . 1 . 0 . 0 .		
	Andre' C. Stevenson	2812	
The MAILING DATE of this communication appears on the cover sheet with the correspondence addressAll claims being allowable, PROSECUTION ON THE MERITS IS (OR REMAINS) CLOSED in this application. If not included herewith (or previously mailed), a Notice of Allowance and Issue Fee Due or other appropriate communication will be mailed in due course.			
 This communication is responsive to July 28, 2004. The allowed claim(s) is/are 1-4. The drawings filed on 31 May 2001 are acceptable. Acknowledgment is made of a claim for foreign priority un a) All b) Some* c) None of the CERTI. received. received in Application No. (Series Code / Set 3. received in this national stage application from the Certified copies not received: Acknowledgement is made of a claim for domestic priority 	FIED copies of the priority docu erial Number) m the International Bureau (PC		
A SHORTENED STATUTORY PERIOD FOR REPLY to comply with the requirements noted below is set to EXPIRE THREE MONTHS FROM THE "DATE MAILED" of this Office Action. Failure to timely comply will result in ABANDONMENT of this application. Extensions of time may be available under the provisions of 37 CFR 1.136(a).			
6. Note the attached EXAMINER'S AMENDMENT or NOTICE OF INFORMAL APPLICATION (PTO-152) which gives reason(s) why the oath or declaration is deficient. A SUBSTITUTE OATH OR DECLARATION IS REQUIRED.			
 7. Applicant MUST submit NEW FORMAL DRAWINGS (a) because the originally filed drawings were declared be including changes required by the Notice of Draftspe 1) hereto or 2) to Paper No. (c) including changes required by the proposed drawing (d) including changes required by the attached Examine 	rson's Patent Drawing Review(·	-
Identifying indicia such as the application number (see 37 CFR 1.84(c)) should be written on the reverse side of the drawings. The drawings should be filed as a separate paper with a transmittal letter addressed to the Official Draftsperson.			
8. Note the attached Examiner's comment regarding REQUI	REMENT FOR THE DEPOSIT	OF BIOLOGICAL MATERIAL.	
Any reply to this letter should include, in the upper right hand corner, the APPLICATION NUMBER (SERIES CODE / SERIAL NUMBER). If applicant has received a Notice of Allowance and Issue Fee Due, the ISSUE BATCH NUMBER and DATE of the NOTICE OF ALLOWANCE should also be included.			
Attachment(s)	•		
 Notice of References Cited (PTO-892) Notice of Draftperson's Patent Drawing Review (PTO-948) Information Disclosure Statements (PTO-1449), Paper No. 2 Examiner's Comment Regarding Requirement for Deposit of Biological Material 	4☐ Interview 9 2. 6☐ Examiner's	nformal Patent Application (PTO-152) Summary (PTO-413), Paper No s Amendment/Comment s Statement of Reasons for Allowance	

Detailed Action

Acknowledgment is made of applicant's claim for foreign priority under 35 U.S.C. 119(a)-(d). The certified copy has been filed in parent Application No. 09867423, filed on May 31, 2001.

Election/Restriction

Claims 5-14 have been withdrawn from further consideration pursuant to 37 CFR 1.142(b) as being drawn to a nonelected invention, there being no allowable generic or linking claim. Election was made without traverse in the reply filed on July 28, 2004.

Claims 5-14 have been canceled as per request in response dated July 28, 2004.

Specifications

The specification has not been checked to the extent necessary to determine the presence of all possible minor errors. Applicant's cooperation is requested in correcting any errors of which applicant may become aware in the specification.

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Allowable Subject Matter

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The following is an examiner's statement of reasons for allowance: While the

prior art teaches drain electrodes that are sequential, it fails to teach a black matrix

being of a same shape above a channel region formed in said semiconductor layer

when seen in a deposit direction.

Any comments considered necessary by applicant must be submitted no later

than the payment of the issue fee and, to avoid processing delays, should preferably

accompany the issue fee. Such submissions should be clearly labeled "Comments on

Statement of Reasons for Allowance."

Claims #1 through 4 are allowed.

Claim #1

> Drain electrodes are deposited sequentially, and said ohmic layer, source and

drain electrodes, and black matrix being of a same shape above a channel region

formed in said semiconductor layer when seen in a deposit direction.

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Information regarding the status of an application may be obtained from the Patent

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Application Information Retrieval (PAIR) system. Status information for published applications

may be obtained from either Private PAIR or Public PAIR. Status information for unpublished

applications is available through Private PAIR only. For more information about the PAIR

system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR

system, contact the Electronic Business Center (EBC) at 866 – 217 – 9197 (toll-free).

Any inquiry concerning this communication or earlier communications from the

examiner should be directed to Andre C. Stevenson whose telephone number is (571) 272 1683.

The examiner can normally be reached on Monday through Friday from 8:00 am to 5:00 pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's

supervisor, John Niebling, can be reached on (571) 272 1683. The fax phone number for the

organization where this application or proceeding is assigned is (703) 308 7724.

Any inquiry of a general nature or relating to the status of this application or proceeding

should be directed to the receptionist whose telephone number is (703) 308 1782. Also, the

proceeding number can be used to fax information;

• (703) 872-9306

Andre C. Stevenson

Art Unit 2812

10/13/04

John F. Niebling

Supervisory Patent Examiner

Technology Center 2800